

Electronic doping and scattering by transition metals on graphene

K. Pi, K. M. McCreary, W. Bao, Wei Han, Y. F. Chiang, Yan Li, S.-W. Tsai, C. N. Lau, and R. K. Kawakami*
Department of Physics and Astronomy, University of California, Riverside, California 92521, USA
 (Received 10 June 2009; published 5 August 2009)

We investigate the effects of transition metals (TM) on the electronic doping and scattering in graphene using molecular-beam epitaxy combined with *in situ* transport measurements. The room-temperature deposition of TM onto graphene produces clusters that dope *n* type for all TM investigated (Ti, Fe, and Pt). We also find that the scattering by TM clusters exhibits different behavior compared to $1/r$ Coulomb scattering. At high coverage, Pt films are able to produce doping that is either *n* type or weakly *p* type, which provides experimental evidence for a strong interfacial dipole favoring *n*-type doping as predicted theoretically.

DOI: [10.1103/PhysRevB.80.075406](https://doi.org/10.1103/PhysRevB.80.075406)

PACS number(s): 73.63.-b, 72.10.Fk, 73.23.-b, 73.40.Ns

I. INTRODUCTION

Transition-metal (TM) adatoms and clusters on graphene have recently been a topic of great interest: at low density, they are expected to induce doping, scattering,¹ and novel magnetic²⁻⁴ and superconducting⁵ behavior; at high density (up to continuous coverage), they may locally dope or modify the band structure of graphene.⁶⁻⁸ Because of their importance for graphene-based electronics and the investigation of novel phenomena,¹⁻¹⁴ there have been extensive theoretical studies.^{1-8,13,14} In contrast, the experimental exploration of TM/graphene systems is much more limited.

A key issue to investigate is the charge transfer between the TM and graphene because it is responsible for both the local doping and the charged impurity scattering. Generally, the relative work function (WF) between the TM and the graphene is believed to be an important factor for determining the charge transfer,¹¹ i.e., graphene will be *p* doped (*n* doped) if the TM's WF is larger (smaller) than graphene. Recently, density-functional calculations predict the presence of a strong interfacial dipole that promotes the *n*-type doping of graphene.⁸ However, experimental studies of the local doping by TM contacts have yet to find evidence for this strong interfacial dipole layer.⁹⁻¹²

In this work, we report *in situ* transport measurements of TM/graphene systems as a function of TM coverage for several different metals using a molecular-beam epitaxy (MBE) deposition system with built-in electrical probes. Similar techniques have been applied to study gases,¹⁵ molecules,¹⁶ and alkali-metal¹⁷ adatoms on graphene. The metals used in the study are Ti, Fe, and Pt, with WF of 4.3, 4.7, and 5.9 eV,¹⁸ respectively [the WF of graphene is 4.5 eV (Refs. 19 and 20)]. Surprisingly, at low coverage, the TM clusters dope graphene *n* type, regardless of its WF relative to that of graphene. For the scattering at low coverage, we find that the scattering by TM clusters exhibits different behavior compared to $1/r$ Coulomb scattering. Extending to high coverage, we make the important observation that Pt films are able to produce doping that is either *n* type or weakly *p* type. Because WF considerations alone would predict strong *p*-type doping, this result provides experimental evidence for the strong interfacial dipole favoring *n*-type doping as calculated theoretically.⁸

II. EXPERIMENTAL PROCEDURES

Samples are prepared by mechanical exfoliation of Kish graphite onto a SiO₂/Si substrate (300 nm thickness of SiO₂). Single-layer graphene flakes are identified by optical microscopy and Raman spectroscopy.²¹ Figure 1(a) shows a scanning electron microscope (SEM) image of a typical graphene device with Au/Ti electrodes defined by e-beam lithography. The device is annealed under Ar/H₂ environment at 200 °C for 1 h to remove resist residue^{22,23} and degassed in ultrahigh vacuum at 90 °C for 1 h. The room-temperature MBE deposition of TM atoms (growth

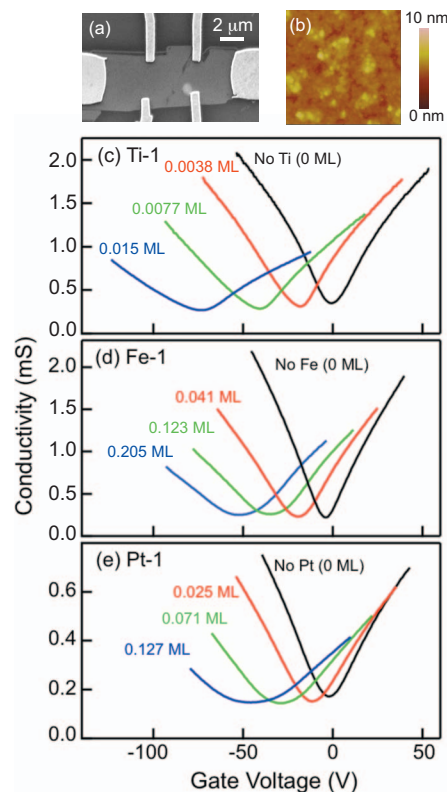


FIG. 1. (Color) (a) SEM image of a graphene device with Au(100 nm)/Ti(10 nm) electrodes. (b) AFM image of 0.01 ML of Pt deposited on single-layer graphene. [(c)–(e)] The gate-dependent conductivity at selected TM coverage for Ti, Fe, and Pt, respectively.

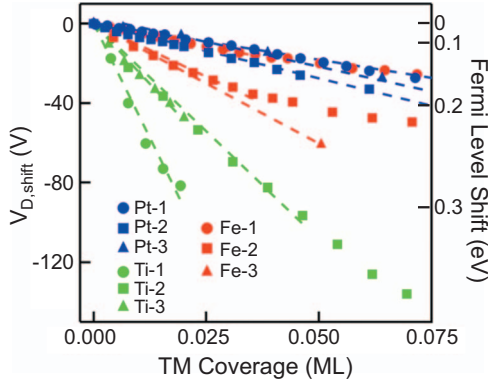


FIG. 2. (Color) Dirac point shift vs coverage for nine separate samples. The dashed lines indicate the linear fit used to define the doping efficiencies, which are: 0.174, 0.092, and 0.082 electrons/atom for Ti-1, Ti-2, and Ti-3, respectively; 0.017, 0.040, and 0.046 electrons/atom for Fe-1, Fe-2, and Fe-3, respectively; 0.014, 0.021, and 0.019 electrons/atom for Pt-1, Pt-2, and Pt-3, respectively.

pressure $< 7 \times 10^{-10}$ torr) is calibrated by a quartz deposition monitor. The coverage is converted from atoms/cm² to “monolayers” (ML), where 1 ML is defined as 1.908×10^{15} atoms/cm², the areal density of primitive unit cells in graphene. For low coverage, the room-temperature deposition of TM leads to clustering as shown in the atomic force microscope (AFM) image of 0.01 ML Pt on graphene [Fig. 1(b)]. The presence of isolated adatoms cannot be ruled out by the AFM but are unfavorable theoretically.⁶ *In situ* transport measurements are performed using standard lock-in detection (1 μ A excitation).

III. RESULTS AND DISCUSSION

The fine control of TM deposition provides the ability to probe the effect of small amounts of material on the transport properties of graphene. Figure 1(c) shows representative gate-dependent conductivity scans for various thicknesses of Ti in the low-coverage regime. The minimum in the gate-dependent conductivity identifies the position of the Dirac point (V_D) while the slope corresponds to the mobility of charge carriers in the graphene. With increasing coverage, two characteristic behaviors are observed. First, the introduction of Ti on the graphene surface results in shifting the Dirac point toward more negative gate voltages, indicating that the Ti is a donor, producing *n*-type doping in the graphene. Second, the slope of the conductance curves away from the Dirac point decreases, indicating that the Ti introduces additional scattering to lower the mobility. Both of these characteristics are also observed for Fe doping [Fig. 1(d)] and Pt doping [Fig. 1(e)].

Figure 2 highlights the relation between the Dirac point shift ($V_{D,shift} = V_D - V_{D,initial}$) and TM coverage for a collection of Ti, Fe, and Pt samples in the low-coverage regime. Despite the sample-to-sample variations which may be due to differences in the graphene surface purity, growth rate uncertainties, and the possible dependence of graphene WF on flake size or edge roughness,²⁴ several important features are discovered. First, all samples, including the Pt samples

with WF greater than graphene, result in *n*-type doping. Second, the three different TM result in three different ranges for slopes, with the Ti samples exhibiting the most negative initial slopes (-2169 to -4602 V/ML). From this value the doping efficiency or number of electrons transferred per Ti atom to graphene is determined by knowing the carrier concentration associated with the given change in gate voltage ($\Delta n = \alpha \Delta V_g$, where $\alpha = 7.2 \times 10^{10}$ V⁻¹ cm⁻² based on calculated capacitance values). The doping efficiency is in the range of 0.082–0.174 electrons per Ti atom. The Fe shows the next strongest efficiency (0.017 to 0.046) while the Pt is the weakest electron donor with the efficiency of 0.014 to 0.021 electrons transferred for each Pt atom. Upon recalling the bulk WFs of Ti (4.3 eV), Fe (4.7 eV), and Pt (5.9 eV), it is apparent that the WF of the TM is related to the doping efficiency, with electrons being more easily transferred from the lowest WF material, Ti, compared to the highest WF material, Pt. However, the magnitudes of the doping efficiency do not vary linearly with the WF of the TM. Therefore, in addition to the work function, other effects such as wave-function hybridization or structural modifications may contribute to the electronic doping of graphene.

Figures 3(a)–3(c) show the conductivity as a function of carrier concentration [$n = -\alpha(V_g - V_D)$]. The electron and hole mobilities are determined by taking the slope of the conductivity away from the Dirac point ($\mu_{e,h} = |\Delta\sigma/e\Delta n|$).^{15,17} Figures 3(d)–3(f) illustrate the detailed dependence of mobility on the TM coverage for Ti, Fe, and Pt samples in the low-coverage regime. Comparing the different samples at equivalent coverages, the Ti exhibits the strongest scattering and Pt has the weakest scattering. Noting that the trend in the scattering (Ti > Pt) matches that of the doping efficiency, we investigate this relationship by plotting the normalized mobility²⁵ against the Dirac point shift [Fig. 3(g)]. The average mobility, $\mu = (\mu_e + \mu_h)/2$, is plotted for Ti and Pt. The Fe samples typically exhibit a reduction in hole mobility which is most pronounced in sample Fe-2, so μ_e and μ_h are plotted separately. Comparing the different materials shows that the mobility reduction in Ti, Pt, and Fe (electrons) is much more strongly related to the Dirac point shift than the TM coverage [Fig. 3(g)]. Because the Dirac point shift not only measures the doping level in the graphene but also the average charge density of the TM, the data shows that the scattering is related to the average charge density of the clusters—a characteristic, that is, plausible for Coulomb scattering. However, we point out that this behavior is actually different from what is calculated for Coulomb scattering by pointlike scatterers with $1/r$ potential.²⁶ Specifically, in Ref. 26, the scattering per impurity does not scale linearly with the impurity charge (α_e) and instead has a strong quadratic component, resulting in scattering that scales as $\alpha_e^2 n_{imp} = \alpha_e (\alpha_e n_{imp}) \sim \alpha_e (V_{D,shift})$. Due to the presence of the material-dependent α_e factor (i.e., doping efficiency), the mobility vs Dirac point shift curves should be significantly different for different materials. Therefore, the observed scattering by TM clusters exhibits behavior that differs from $1/r$ Coulomb scattering by isolated impurities.¹

Additionally, we analyze the power-law relationship between the scattering and doping effects. The total scattering rate is $\Gamma = \Gamma_0 + \Gamma_{TM}$, where Γ_0 is the scattering rate of the

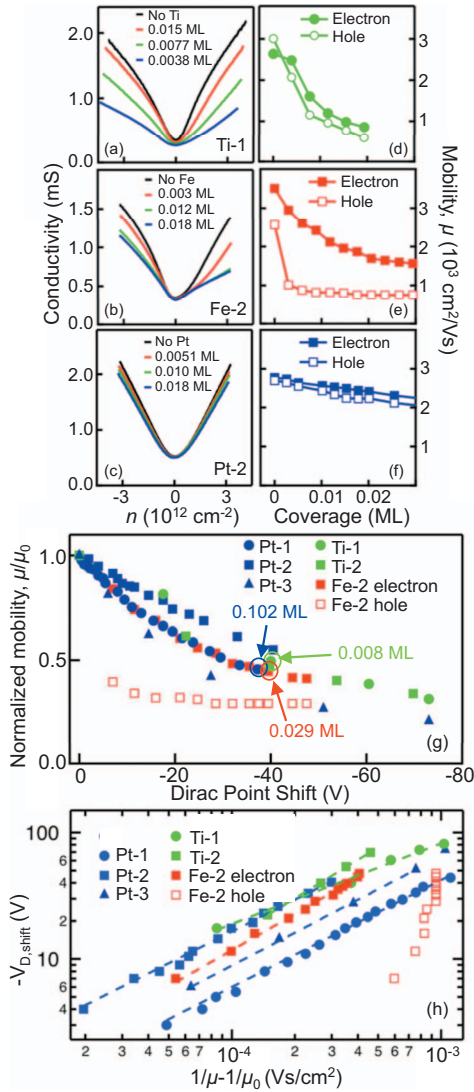


FIG. 3. (Color) [(a)–(c)] The conductivity vs carrier concentration for Ti, Fe, and Pt, respectively, for four different TM coverages. [(d)–(f)] The electron and hole mobilities for Ti, Fe, and Pt, respectively, as a function of TM coverage. (g) The normalized mobility (μ/μ_0) vs Dirac point shift. The data points corresponding to 0.102 ML Pt, 0.008 ML Ti, and 0.029 ML Fe on samples Pt-1, Ti-1, and Fe-2 are circled. (h) $-V_{D,\text{shift}}$ is plotted vs $1/\mu - 1/\mu_0$. The dashed lines are power-law fits to the equation, $-\Delta V_{D,\text{shift}} \sim (\Gamma_{\text{TM}})^b$, where b is 0.64, 1.01, 0.85, 0.83, 0.86, and 0.95 for Ti-1, Ti-2, Pt-1, Pt-2, Pt-3, and Fe-2 electrons, respectively.

undoped sample and Γ_{TM} is the scattering rate induced by the TM. Because mobility is inversely proportional to scattering, the quantity $1/\mu - 1/\mu_0$ is proportional to Γ_{TM} . The relationship between the Dirac point shift and Γ_{TM} is investigated by plotting $-\Delta V_{D,\text{shift}}$ vs $1/\mu - 1/\mu_0$ on a log-log scale [Fig. 3(h)]. The dashed lines are power-law fits, $-\Delta V_{D,\text{shift}} \sim (\Gamma_{\text{TM}})^b$, with values of b ranging from 0.64–1.01 as indicated in the figure caption. Compared to the results of Chen *et al.*¹⁷ which find values of $b=1.2$ – 1.3 for scattering by isolated potassium impurities, our results with $b \leq 1$ indicate a different behavior for scattering by TM clusters.

A surprising result from the studies at low coverage (Figs. 1–3) is the n -type doping of graphene by Pt. If the WF is the

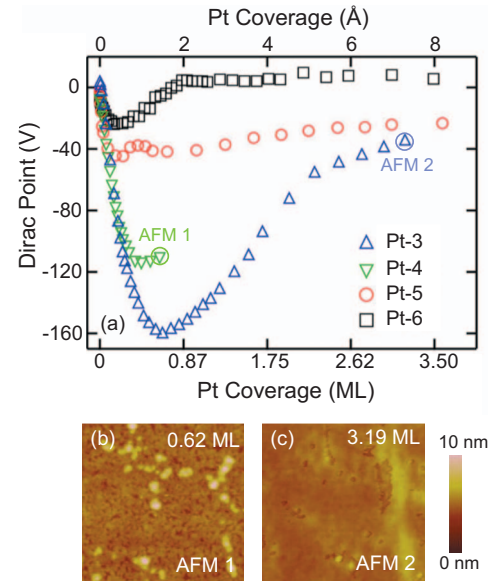


FIG. 4. (Color) (a) The Dirac point as a function of Pt coverage up to high coverage. (b) AFM image of 0.62 ML Pt exhibits isolated clusters. (c) AFM image of 3.19 ML Pt indicates a connected film with some areas of bare graphene.

only factor affecting the transfer of electrons between materials, Pt is expected to dope graphene strongly p type, since the WF of Pt (5.9 eV) is significantly larger than that of graphene (4.5 eV). Density-functional calculations of bulk TM on graphene⁸ present a possible explanation for this observed behavior by predicting the formation of an interfacial dipole layer resulting in a potential step to favor n -type doping ($\Delta V=0.9$ eV). So far, however, there has been no experimental evidence for such a strong dipole layer forming at the interface between a bulk TM and graphene.^{9–12} To investigate the theoretical prediction of a strong interfacial dipole layer between the graphene and bulk TM, we extend the Pt-doping study to higher coverage to study the charge transfer from Pt films. Figure 4(a) displays V_D as a function of coverage for several Pt-doped samples. An initial rapid shift toward negative voltages is observed in all samples. As more Pt is deposited, bringing the sample into the medium-coverage regime, the rate of shift in V_D slows and reaches a minimum value before gradually increasing toward more positive voltages. At high coverage, the Dirac point stabilizes and shows very little variation with additional deposition. The sample morphology is measured by *ex situ* AFM. The AFM image for 0.62 ML of Pt shows that the Pt is still in the form of isolated clusters [Fig. 4(b)]. At the higher coverage of 3.19 ML, the Pt forms a connected film with some uncovered regions of graphene [Fig. 4(c)]. The connected film provides a parallel conduction pathway that contributes to the measured conductivity value but should not be gate dependent. The gate dependence of the conductivity is primarily due to the chemical-potential shift in the graphene that is not covered by the metal. For graphene in direct contact with the metal, the local chemical potential is pinned, exhibiting no gate dependence. However, the gate dependence of the uncovered graphene regions and the voltage of the conductance minima (V_D) still provide a reliable measure of the electronic

doping by the TM due to the continuity of the chemical potential. Thus, the final values of V_D in the high-coverage regime clearly show that Pt films can produce either n -type or weak p -type doping of the graphene. This sample-to-sample variation is most likely due to differences in the initial surface purity among samples. Although hydrogen cleaning is performed on all samples, trace amounts of resist residue could remain, directly affecting the TM-graphene spacing. Due to the highly spacing-dependent interfacial dipole strength,⁸ any variation in the spacing will directly affect the type and amount of doping. The fact that n -type doping is observed provides experimental evidence for the presence of a strong interfacial dipole layer favoring n -type doping as predicted theoretically⁸ because the expected doping based only on WF considerations would lead to strong p -type doping.

An interfacial dipole whose strength decreases with increasing equilibrium spacing (d_{eq}) (Ref. 8) provides a possible explanation for the nonmonotonic behavior of the Dirac point shift in Pt samples. Based on theoretical calculations, the d_{eq} between TM adatoms and graphene is less than 3 Å (Ref. 6) while for bulk TM the distance increases to ~ 3.3 Å.⁸ The n -type doping observed in samples at low coverage is an indication of a strong interfacial dipole favoring n -type doping, as expected for low coverages exhibiting a small d_{eq} . As the bulklike regime is approached, the increasing d_{eq} decreases the dipole strength and hence reduces the n -type doping efficiency as observed by the shift in the Dirac point toward positive voltages. We emphasize that the interfacial dipole provides just one possible scenario to explain the nonmonotonic evolution of the Dirac point shift. A quantitative understanding is complicated by the fact that the WF can differ from bulk values for small clusters (< 4 nm

lateral size) (Ref. 27) and the corresponding quantity for adatoms (should they be present) is the first ionization energy. Therefore, further theoretical calculations are needed to fully understand the doping effect of clusters. Regardless of the exact mechanism for doping by clusters, an interfacial dipole is still necessary to explain the n -type or weak p -type doping measured in the bulklike regime.

IV. CONCLUSION

In conclusion, the exploration of TM/graphene systems leads to several important observations. At low coverage, the doping efficiency is found to be related to the TM WFs but Ti, Fe, and Pt all exhibit n -type doping even for materials with higher WF than graphene (i.e., Fe and Pt). Extending the Pt-doping study to higher thickness, the doping can either be n type or weakly p type. Because WF considerations alone would generate strong p -type doping, this result provides experimental evidence for the strong interfacial dipole favoring n -type doping as predicted by theory.⁸ Analysis of the scattering at low coverage indicates that the scattering by TM clusters exhibits different behavior compared to $1/r$ Coulomb scattering.

ACKNOWLEDGMENTS

We acknowledge helpful discussions with F. Guinea and M. Fuhrer. We acknowledge the support of ONR (Grant No. N00014-09-1-0117), NSF (Grants No. CAREER DMR-0450037, No. CAREER DMR-0748910, and No. MRSEC DMR-0820414), and CNID (Grant No. ONR/DMEA-H94003-07-2-0703).

*roland.kawakami@ucr.edu

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